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AUG 30 2004

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE
PATENT APPLICATION

Application No.: 09/683,088
Applicant: Chu et al.
Filing Date: November 16, 2001
Title: **SINGLE REACTOR, MULTI-
PRESSURE CHEMICAL VAPOR
DEPOSITION FOR SEMICONDUCTOR
DEVICES**

Atty. Docket: BUR9-2000-0077-US1
Today's Date: August 30, 2004
Examiner: Matthew J. Song
Group Art Unit: 1765
Fax: 703-872-9306

Amendments Under 37 CFR 1.114

Amendment C

Honorable Commissioner for Patents and Trademarks
Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated May 28, 2004, Applicants respectfully request reconsideration of the outstanding rejections and reexamination of the present application in light of the following amendments and remarks for which a timely response is being filed on Monday, August 30, 2004 within the three month period for reply.

CERTIFICATE OF MAILING	
I hereby certify that, on the date shown below, this correspondence is being:	
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<input type="checkbox"/> deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Commissioner for Patents, Alexandria, VA 22313-1450.	<input checked="" type="checkbox"/> transmitted by facsimile to the Patent and Trademark Office.
Date: <u>AUG. 30, 2004</u>	<u>ANTHONY J. CANAZE</u> Name
	<u>Anthony J. Canale</u> Signature

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